

First International Conference on Nanoimprint and Nanoprint Technology (NNT)

San Francisco, California
December 11-13, 2002

Program Overview

The NNT conference is the first and most extensive forum to address the rapid developments of nanoimprint and nanoprint technology, as well as their applications across multiple disciplines. The conference will have oral presentations, posters, and commercial exhibitions. Topics include:

- Nanoimprint • Nanoprint • Soft-lithography • Dip-pen lithography
- Tooling • Applications in electronics, optoelectronics, magnetics, materials, self-assembly, chemistry, biology, and pharmaceuticals

Program Committee

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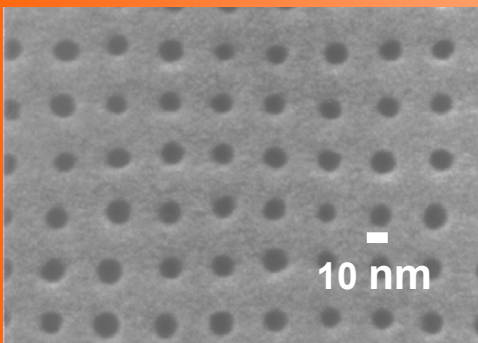
Dan Herr, SRC

Dave Patterson, DARPA

Gernot Pomrenke, AFOSR

Abstract Submission: September 1, 2002, via Internet. More info in June. (www.avs.org)

Hotel: San Francisco Marriott. Detail information will be available in June.



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